

Docket No.

0160-0193-0 PCT

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

IN RE APPLICATION OF: Hiroshi IKEDA, ET AL.

GAU:

1754

SERIAL NO: 09/463,961

EXAMINER: VANOY, T.

FILED:

MAY 25, 2000

FOR:

METHOD AND APPARATUS FOR PROCESSING EXHAUST GAS OF SEMICONDUCTOR FABRICATION

REQUEST FOR EXTENSION OF TIME UNDER 37 C.F.R. 1.136

ASSISTANT COMMISSIONER FOR PATENTS WASHINGTON, D.C. 20231

SIR:

RECEIVED

It is h

is hereby requested that a one month extension of time be granted to OCIOBI	FK 19, 2001 100 CT 0 3 2	<u> 1</u> 001
filing a response to the Official Action dated: JUNE 19, 2001	TO 474	20
responding to the requirements in the Notice of Allowability dated:	TC 170	
☐ filing the Formal Drawings. The Issue Fee due has	s been timely filed.	•
responding to the Notice to File Missing Parts of Application dated:		
☐ filing a Notice of Appeal. A timely response to the final rejection, due	has be	een filed.
☐ filing an Appeal Brief. A Notice of Appeal was filed on:		
☐ Applicant claims small entity status. See 37 CFR 1.27. Therefore, the fee	amount shown below is red	uced by one-half.

The required fee of \$110.00 is enclosed herewith by check and any further charges may be made against the Attorney of Record's Deposit Account No. 15-0030. A duplicate copy of this sheet is enclosed.

Respectfully Submitted,

OBLON, SPIVAK, McCLELLAND, MAIER & NEUSTADT, P.C.

Norman F. Oblon

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